



2014 International Workshop on EUV Lithography

Makena Beach & Golf Resort, Maui, Hawaii

June 23-27, 2014

FIRST CALL FOR PAPERS

We are inviting presentations and poster papers for the 2014 International Workshop on EUV Lithography to be held from June 23-27, 2014, in Makena Beach Golf Resort, Maui, Hawaii, USA. This workshop, now in its seventh year, is focused on fundamental science of EUV Lithography (EUVL). Smaller group setting suitable for networking and brainstorming, with a focus on fundamentals, sets this conference apart from other larger conferences focused on commercial aspects of EUVL.

Technology review papers and papers with innovative approaches to address current EUV Lithography related technical challenges are encouraged. EUV Lithography related topics covered under this workshop are: source for HVM and metrology, exposure tools, masks, optics, resist, contamination, metrology, patterning and cost of ownership. Papers on combination of EUVL with multiple patterning and DSA are also welcome.

On June 23rd, 2014 EUV Lithography Short Course will be offered. The workshop will start with registration and registration on June 24th and will be followed by presentations, panel discussions and a poster session on June 25th and 26th. The workshop will conclude with a Steering Committee meeting on June 27th, 2014, which is open to all workshop attendees. The keynote speakers for the 2014 workshop will be announced soon on our website www.euvlitho.com.

The 2014 International Workshop on EUV Lithography is organized by EUV Litho, Inc.

Instructions for Submissions and Deadlines

Please submit abstracts of less than 200 words. Indicate whether an oral or poster paper is preferred. Please include full name, email, and mailing address for all authors. Abstracts should be submitted via email to abstracts@euvlitho.com

The deadline for abstract submission is March 14th, 2014. Abstracts will be evaluated by the workshop's technical Steering Committee for inclusion in the workshop. Authors will be notified by March 31st or earlier, if their abstracts have been accepted for an oral or poster paper.

Contact Information

For meeting-related issues please contact: meeting.planner@euvlitho.com

For technical questions, please contact: vivek.bakshi@euvlitho.com